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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
10/606,182	06/26/2003	Tsutomu Hashizume	Q76316	1591
7590 08/24/2005			EXAMINER	
SUGHRUE, MION, ZINN, MACPEAK & SEAS			FEGGINS, KRISTAL J	
2100 Pennsylva	nia Avenue, N.W.			
Washington, D			ART UNIT	PAPER NUMBER
			2861	

DATE MAILED: 08/24/2005

Please find below and/or attached an Office communication concerning this application or proceeding.

9	Application No.	Applicant(s)	10			
	10/606,182	HASHIZUME ET AL.				
Office Action Summary	Examiner	Art Unit				
	K. Feggins	2861				
The MAILING DATE of this communication Period for Reply	appears on the cover sheet v	vith the correspondence addre	ess			
A SHORTENED STATUTORY PERIOD FOR RE THE MAILING DATE OF THIS COMMUNICATIO - Extensions of time may be available under the provisions of 37 CFI after SIX (6) MONTHS from the mailing date of this communication - If the period for reply specified above is less than thirty (30) days, a - If NO period for reply is specified above, the maximum statutory pe - Failure to reply within the set or extended period for reply will, by st Any reply received by the Office later than three months after the mearned patent term adjustment. See 37 CFR 1.704(b).	ON. R 1.136(a). In no event, however, may a b. a reply within the statutory minimum of the criod will apply and will expire SIX (6) MC tatute, cause the application to become A	a reply be timely filed inty (30) days will be considered timely. DNTHS from the mailing date of this commandate of this comm	nunication.			
Status						
1) Responsive to communication(s) filed on _						
, —	This action is non-final.					
3) Since this application is in condition for allo	, 					
Disposition of Claims						
4) ⊠ Claim(s) 21-33 is/are pending in the application 4a) Of the above claim(s) is/are with 5) □ Claim(s) is/are allowed. 6) ⊠ Claim(s) 21-33 is/are rejected. 7) □ Claim(s) is/are objected to. 8) □ Claim(s) are subject to restriction are	drawn from consideration.					
Application Papers						
9) The specification is objected to by the Exam 10) The drawing(s) filed on is/are: a) Applicant may not request that any objection to Replacement drawing sheet(s) including the col 11) The oath or declaration is objected to by the	accepted or b) objected to the drawing(s) be held in abeya rrection is required if the drawin	ance. See 37 CFR 1.85(a). g(s) is objected to. See 37 CFR				
Priority under 35 U.S.C. § 119						
12) Acknowledgment is made of a claim for fore a) All b) Some * c) None of: 1. Certified copies of the priority docum 2. Certified copies of the priority docum 3. Copies of the certified copies of the application from the International Bu * See the attached detailed Office action for a	nents have been received. nents have been received in priority documents have bee reau (PCT Rule 17.2(a)).	Application No on received in this National Sta	age			
Attachment(s)						
 Notice of References Cited (PTO-892) Notice of Draftsperson's Patent Drawing Review (PTO-948) 		y Summary (PTO-413) o(s)/Mail Date				
Notice of Draitsperson's Patent Drawing Review (F10-946 Information Disclosure Statement(s) (PT0-1449 or PT0/SE Paper No(s)/Mail Date	′ — —	f Informal Patent Application (PTO-15	52)			

DETAILED ACTION

Claim Rejections - 35 USC § 102

1. The following is a quotation of the appropriate paragraphs of 35 U.S.C. 102 that form the basis for the rejections under this section made in this Office action:

A person shall be entitled to a patent unless -

- (e) the invention was described in (1) an application for patent, published under section 122(b), by another filed in the United States before the invention by the applicant for patent or (2) a patent granted on an application for patent by another filed in the United States before the invention by the applicant for patent, except that an international application filed under the treaty defined in section 351(a) shall have the effects for purposes of this subsection of an application filed in the United States only if the international application designated the United States and was published under Article 21(2) of such treaty in the English language.
- 2. Claims 21-33 are rejected under 35 U.S.C. 102(e) as being anticipated by Hasegawa et al. (US 5,530,465).

Hasegawa et al. disclose the following claimed limitations:

- * regarding claims 21, 25 & 30 an ink jet recording head formed by a method and a method of manufacturing an ink jet recording head (Abstract);
 - * forming a first/lower/ electrode layer/104/ on a diaphragm/103/ (figs 2A-C);
- * forming a piezoelectric layer/105/ on the first/lower/ electrode layer/104/ (figs 2A-C);
- * forming a second/upper/ electrode layer/106/ on the piezoelectric layer/105/ (figs 2A-C);
- * etching completely through the second/upper/ electrode layer/106/, the piezoelectric layer/105/, and the first/lower/ electrode layer/104/ so that a portion/the ends/ of the diaphragm/103/ is exposed (figs 2A-C, col 9, lines 41-67; etching pertains to the method of making, it is not a structural feature of the device).

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* regarding claims 22, 26 & 31, wherein the diaphragm/103/ is attached to a substrate/101/(figs 2A-C).

- * regarding claim 29, wherein only a single mask material is used to pattern the second electrode layer/106/, the piezoelectric layer/105/, and the first electrode layer/104/ during the etching step (figs 2A-C, col 9, lines 41-67).
- * further regarding claim 30, etching completely through at least the second electrode layer and the piezoelectric layer so that a portion of the diaphragm is exposed (figs 2A-C, col 9, lines 41-67).

Claim Rejections - 35 USC § 103

- 3. The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:
 - (a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.
- 4. Claims 23, 24, 27, 28, 32, 33 are rejected under 35 U.S.C. 103(a) as being unpatentable over Hasegawa et al. (US 5,530,465) in view of Miyata et al. (US 5,754,205).

Hasegawa et al. disclose all of the claimed limitations except for the following:

* regarding claims 23, 27 & 32, wherein a nozzle plate is attached to the substrate.

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orifice.

* regarding claims 24, 28 & 33, wherein the nozzle plate is formed with a nozzle

Miyata et al. disclose the following claimed limitations:

* regarding claims 23, 27 & 32, wherein a nozzle plate/53/ is attached to the

substrate (col 7, lines 39-42, fig 3b) for the purpose of providing a plurality of nozzle

openings fixed to one face of the substrate.

* regarding claims 24, 28 & 33, wherein the nozzle plate/53/ is formed with a

nozzle orifice/52/ (col 7, lines 39-42, fig 3b) for the purpose of ejecting ink drops

through the nozzle opening.

It would have been obvious at the time of the invention was made to a person

having ordinary skill in the art to utilize a nozzle plate is attached to the substrate; and a

nozzle plate that is formed with a nozzle orifice, taught by Miyata et al. into Hasegawa

et al. for the purposes of providing a plurality of nozzle openings fixed to one face of the

substrate and ejecting ink drops through the nozzle opening.

Response to Arguments

5. Applicant's arguments with respect to claims 21-33 have been considered but are

moot in view of the new ground(s) of rejection. Hasegawa et al. discloses a liquid jet

head having a silicon substrate, a piezoelectric device, upper and lower electrodes and

a piezoelectric film and utilizing etching to manufacture the device.

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Communication With The USPTO

6. Any inquiry concerning this communication or earlier communications from the examiner should be directed to K. Feggins whose telephone number is 571-272-2254. The examiner can normally be reached on M-F.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Talbott Dave can be reached on 571-272-1934. The fax phone number for the organization where this application or proceeding is assigned is 703-872-9306.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

PRIMARY EXAMINER